## Modular AFM / STM System SOLVER Nano

Suitable for both scientific research and nanotechnology education

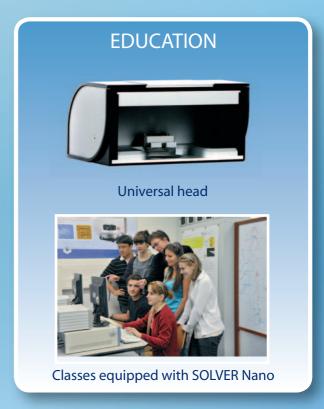


- AFM / STM atomic resolution
- All AFM/STM modes and nanolithography
- New digital controller
- Closed-loop scanner
- Easy Laser Photodiode alignment
- Remote control via the Internet
- Data sharing via iPhone<sup>™</sup> and iPad<sup>™</sup>

iPhone™, iPad™ are registered trademarks or trademarks of Apple Inc.

## Easy-to-transform solution for:





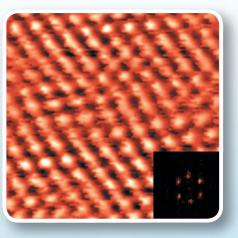




Blood cells. Scan size  $50 \times 50 \ \mu m$ . Semicontact mode



Microstructure. Scan size  $30 \times 30 \ \mu m$ . Semicontact mode



Atomic lattice of HOPG. Scan size 4×4 nm. Contact lateral force mode

## Specifications:

<u> </u>	
Scanning:	By sample, range $100 \times 100 \times 10 \mu\text{m}$ (Closed Loop)
Sample positioning:	Manual, range 5×5 mm
Sample weight:	Up to 40 g
Sample size:	Diameter up to 25 mm, Thickness up to 10 mm
Approach system	By sample, motorized, range 15 mm
Optical control:	Embedded USB camera
Scanning Tunneling Microscopy (STM):	<ul><li>Constant Current</li><li>Constant Height</li><li>I(Z) spectroscopy</li><li>I(V) spectroscopy</li></ul>
Atomic Force Microscopy (AFM)	<ul> <li>Topography imaging</li> <li>Phase imaging</li> <li>Magnetic-force microscopy</li> <li>Electrostatic force microscopy</li> <li>Spreading resistance imaging</li> <li>Kelvin probe microscopy</li> <li>Force-distance curves</li> <li>Amplitude-distance curves</li> <li>I(V) spectroscopy</li> </ul>
AFM Lithography	<ul><li>Force lithography</li><li>Current lithography</li><li>Vector\raster lithography</li></ul>

